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HG

**CHEMICAL INDUSTRY STANDARD OF THE
PEOPLE'S REPUBLIC OF CHINA**

HG/T 6267-2024

**Method for determining fluorine content in copper-containing
etching waste liquid
(English Translation)**

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What this standard covers

This standard specifies the general provisions and determination methods for the determination of fluorine content in copper-containing etching waste liquid. This standard is applicable to the determination of fluorine content in copper-containing etching waste liquid of printed circuit boards (PCBs). The lower limit of determination by the ion selective electrode single standard addition method is 1.6 mg/L, the lower limit of determination by the ion selective electrode standard curve method is 1.8 mg/L, and the lower limit of determination by the ion chromatography method is 0.8 mg/L.

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